

Helium reflectivity and Debye temperature of graphene grown epitaxially on Ru(0001)

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It is shown that the surface of an epitaxial graphene monolayer grown on Ru(0001) could be used as a quite efficient external mirror for He-atom microscopy, with a specular reflectivity of 20% of the incident beam. Furthermore, the system is stable up to 1150 K, and the He reflectivity remains almost unchanged after exposure to air. Additionally, the high reflectivity for H₂ molecules (11%) opens up the development of a H₂ microprobe suitable for lithography. The Debye temperature for this epitaxial graphene monolayer has been determined from a study of the temperature dependence of the He specular intensity as a function of incident parameters. A value of 1045 K has been obtained, which is much higher than the 590 K reported for graphite under similar conditions, and close to the value of 1287 K calculated for isolated graphene.

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I. INTRODUCTION

Much effort has been devoted in recent years to the development of a scanning helium-atom microscope (SHeAM),^{1–4} in which a focused beam of neutral He atoms is used as imaging probe. In fact, the first micrograph using helium atoms as an imaging probe has been reported recently.² The development of a SHeAM would imply a substantial improvement of our present knowledge of delicate biological materials, weak polymers, ceramics, and insulating glass surfaces, among other materials. Such samples are difficult to examine by electron microscopy techniques, due to sample charging or electron excitation effects. Likewise, scanning tunneling microscopy (STM) cannot be used, as it works only on conductive substrates. Atomic force microscopy could in principle be employed on these surfaces, but the complex tip-sample interaction often jeopardizes the interpretation of images.

On the other hand, and due to the low energies employed (~ 10 – 100 meV), neutral helium atoms probe the topmost surface layer of any material in an absolutely nondestructive manner.⁵ Electron microscopes and x-ray microscopes as well as the recently developed helium-ion microscope^{6,7} all operate with beam energies in the keV range. In contrast, the low energy of the impinging neutral He atoms employed in SHeAM would avoid the appearance of unwanted beam-induced effects, including sputtering and the excitation of many surface modes like single-particle excitations and plasmons.

Currently, the main limitation for developing SHeAM is related to the focusing of atomic beams. Two different solutions are possible. The first one is the use of Fresnel zone plates,^{8,9} which presents the disadvantage of chromatic aberration. The most promising method is to use the He beam specularly reflected from an electrostatically bent single-crystal surface.¹ Bent-crystal mirrors offer both achromatic focusing and large numerical apertures, whereby a high reflectivity is required for practical applications.¹⁰ Present prototypes of the SHeAM use a hydrogen-passivated Si(111)-(1 \times 1) mirror, which exhibits a reflectivity of $\sim 1\%$ for He atoms.¹¹ Such a low intensity of the focused beam limits the present lateral resolution of the SHeAM to about $230\text{ }\mu\text{m}$,¹² although in principle it could be reduced to 50 nm if a larger beam intensity were

available. Therefore, the realization of a more efficient mirror for SHeAM has hitherto been a grand challenge. In general, the main limitation to a high reflectivity is due to the large sensitivity of He atoms to even a small density of surface defects.⁵ In addition, the mirror for the SHeAM should be inert and thermally stable. As an example, despite the high reflectivity of the clean Ru(0001) surface, it is not suitable as a mirror, because its reflectivity is reduced to zero after exposure to reactive species. A clear advantage of inert mirrors is that they could be produced *ex situ* and delivered to the place where the SHeAM is located. We have also shown that quantum-stabilized, ultraflat, and ultrathin films of Pb might reflect substantially better than existing mirrors.¹³ The films, however, were not stable at 300 K. More recently, we showed that the Pb($\sqrt{3} \times \sqrt{3}$)R30°Si(111) surface presents a specular He reflectivity of 15%, and is stable up to 450 K.¹⁴ However, this surface is destroyed by contamination when exposed to air.

Recent work has shown that a monolayer of graphene (MLG) can be grown with excellent crystalline quality on metal surfaces.^{15–18} The preparation of highly ordered graphene can be extended even up to the millimeter scale for epitaxial graphene grown on Ru(0001).¹⁹ No bond breakage was revealed even over the substrate steps. Furthermore, MLG can be grown also on thin films of (0001)-oriented Ru deposited on SiO₂/Si (Ref. 20) and sapphire (0001) (Ref. 21) substrates, so as to allow the practical design of a bent-crystal mirror. Hence, MLG on Ru(0001) could be a good candidate for the construction of a mirror for focusing beams of neutral atoms and molecules, if the reflectivity and stability are appropriate.

In addition, the unusual electronic and optical properties of supported graphene have attracted widespread interest.²² In particular, understanding the atomic dynamics of graphene is interesting in view of the high thermal conductivity of graphene. The simplest view of the dynamics of atoms in two-dimensional systems is given by the Debye temperature,^{23–25} which is related to the thermal vibration of the surface atoms. It provides important information about the thermal stability and hardness of materials, as well as about the strength of the bonds

involved in the surface termination. Atomic beam scattering at thermal energies (~ 10 – 100 meV) provides a reliable way to obtain the surface Debye temperature of any material, since the scattering process is restricted to the outermost surface layer.⁵

In this paper, we show that the surface of an epitaxial graphene monolayer grown on Ru(0001) has a large He specular reflectivity of 20% of the incident beam, is stable up to 1150 K, and is inert after exposure to air. In addition, the high reflectivity obtained for H_2 beams (11%) opens up the development of a H_2 microprobe suitable for lithography and molecular interferometry. Finally, the Debye temperature of the graphene monolayer on Ru(0001) has been found to be 1045 K, which is much higher than the one reported for graphite,²⁶ but surprisingly close to the value of 1287 K recently calculated for out-of-plane vibrations in isolated graphene.³⁴ Possible reasons for this behavior are discussed.

II. EXPERIMENTAL DETAILS

Experiments have been carried out in two different ultrahigh-vacuum (UHV) chambers with base pressures in the low 10^{-10} mbar range. The first one is a helium-atom scattering apparatus described elsewhere.²⁷ Briefly, the angular distribution of the scattered He atoms can be analyzed with a quadrupole mass spectrometer mounted on a two-axis goniometer. The intensity of the incident beam can also be measured and used to normalize scattered beam intensities, thereby yielding absolute diffraction intensities. Since the incident and specular beams have similar widths, this normalization can be made just by comparing the intensities of the incident and specular peaks for given incidence conditions. The sample temperature was measured with a type-C thermocouple spot-welded to the sample. The second chamber contains a variable-temperature STM, employed to check the structural quality of the graphene monolayer.

Atomically clean, bulk-C-depleted, crystalline Ru(0001) surfaces were prepared by standard sputtering-annealing cycles followed by oxygen exposure at 1150 K and a final flash to 1500 K. In both chambers, surface cleanliness and order were also checked using Auger electron spectroscopy and low-energy electron diffraction measurements, respectively. Graphene was obtained by dosing C_2H_4 (ethylene) onto the clean Ru(0001) substrate at 1150 K. The high temperature of the sample during deposition favors increase of the size of monolayer graphene islands²⁸ and, moreover, allows the substrate to be kept clean so as to avoid any contaminant-induced effect on graphene growth. The completion of the first layer was reached upon an exposure to 3×10^{-8} mbar ethylene for 10 min [a dose equivalent to 24 langmuirs (L)]. The temperature was then held at 1150 K for a further 60 s after removing the C_2H_4 gas from the chamber. Such optimal conditions were determined from a combined STM and Helium Atom Scattering (HAS) analysis of graphene growth on Ru(0001). The air exposure was performed by removing the sample from the UHV chamber through a fast load-lock entry and reintroducing it into the UHV chamber for HAS and STM measurements. Oxygen was dosed through a leak valve.

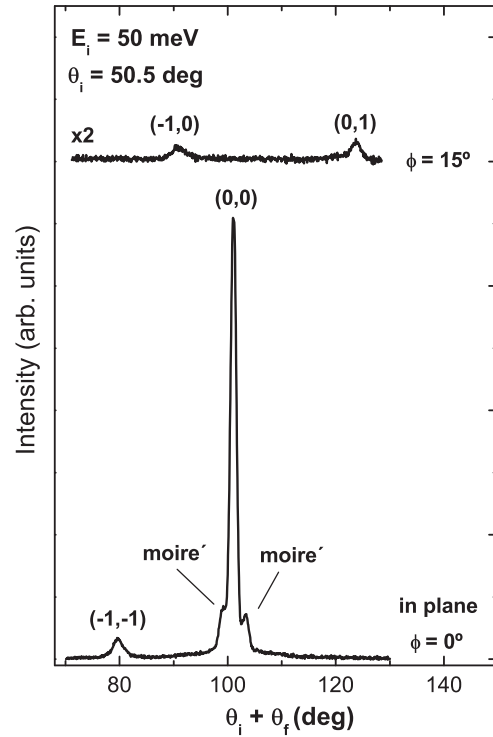


FIG. 1. Angular distribution of a beam of He atoms with an incident energy of 50 meV scattered from the MLG/Ru(0001) surface along the $[11\bar{2}0]$ azimuth. The incident angle is $\Theta_i = 50.5^\circ$. Diffraction peaks corresponding to the graphene overlayer can be seen in both the in-plane and the out-of-plane spectra. The sample temperature is 100 K.

III. RESULTS AND DISCUSSION

Specular scattering dominates the He diffraction pattern of MLG/Ru(0001), as can be seen in the diffraction spectra shown in Fig. 1. The existence of a low-intensity but well-resolved $(\bar{1}\bar{1})$ diffraction peak is the fingerprint of the existence of a well-ordered MLG, also confirmed by STM images (see below). Other weak diffraction features, assigned to the $(\bar{1}0)$ and (01) peaks of MLG, are present in the spectra recorded at 15° out of plane. The in-plane spectrum also shows the first-order peaks corresponding to the moiré superstructure closer to the specular peak. Note the low total intensity of diffracted peaks as compared to that of the specular peak, which is a consequence of the low corrugation of MLG/Ru(0001), estimated as ~ 0.15 – 0.30 Å.²⁹

A comparison of the incident He beam profile with the one corresponding to the specular peak recorded at $E_i = 32$ meV and $\Theta_i = 50^\circ$ is shown in Fig. 2. The specular absolute reflectivity is 20%, which is a factor of ~ 20 times higher than for the H-passivated Si(111) surface under similar scattering conditions.¹¹ Likewise, an 11% reflectivity was obtained for a H_2 beam scattered off MLG/Ru(0001), whereas to date the highest H_2 reflectivity reported for H_2 beams was 2.6% in the case of Si(111)-H(1×1).¹¹ An intense and focused beam of hydrogen might be a promising tool for lithography in wafer-scale fabrication of molecular junctions.³⁰

Helium-atom scattering at thermal energies provides a reliable way to obtain the surface Debye temperature, since the

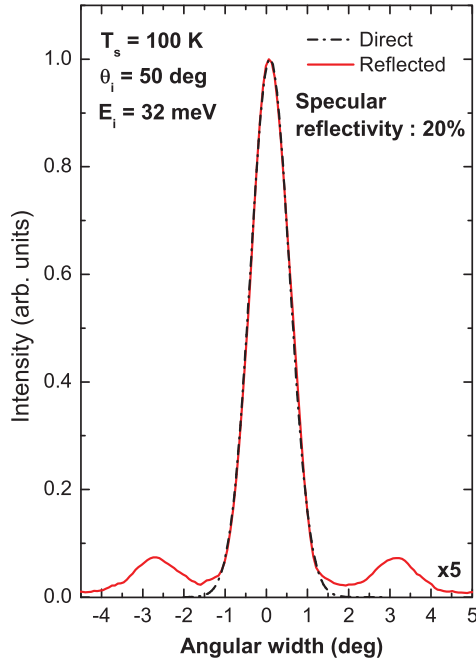


FIG. 2. (Color online) Comparison of the incident He beam intensity with the specular He reflectivity for MLG/Ru(0001). The incident energy is 32 meV.

scattering process occurs at $\sim 3 \text{ \AA}$ away from the topmost atom cores of the solids surface. Both zero-point motion and thermal vibrations of the surface atoms lead to inelastic scattering of the incoming atoms. The main observable effect of this is a thermal attenuation of the coherent diffraction intensities, without a change of the peak shape.³¹ Note also that the Debye temperature values determined using other probes could in principle be slightly different from the one obtained in our experiments.

The thermal attenuation of the specular beam for scattering of He atoms from MLG is shown in Fig. 3 as a function of surface temperature, incident beam energy, and angle of incidence. Note the exponential attenuation of the specular intensity. The exponential temperature dependence was verified for two different angles of incidence ($\Theta_i = 45^\circ$ and 60°) and three different beam energies. For comparison, Fig. 3 also includes the He specular attenuation curve reported in Ref. 26 for highly oriented pyrolytic graphite (HOPG) (which has been rescaled). Again an exponential dependence is observed, but the slope is much larger for HOPG than for MLG/Ru(0001) under almost the same incident conditions (compare the data points for $E_i = 64 \text{ meV}$ and $\Theta_i = 45^\circ$), which indicates a smaller value of the corresponding Debye temperature.

The intensity $I(T)$ of a diffraction peak at finite temperature T is related to the intensity I_0 from the lattice at rest by

$$I(T) = I_0 e^{-2W(T)}, \quad (1)$$

where $\exp[-2W(T)]$ is the Debye-Waller factor. In describing the scattering of thermal atoms from surfaces, the effect of the attractive well near the surface is usually taken into consideration via the so-called “Beeby correction.”³² For the

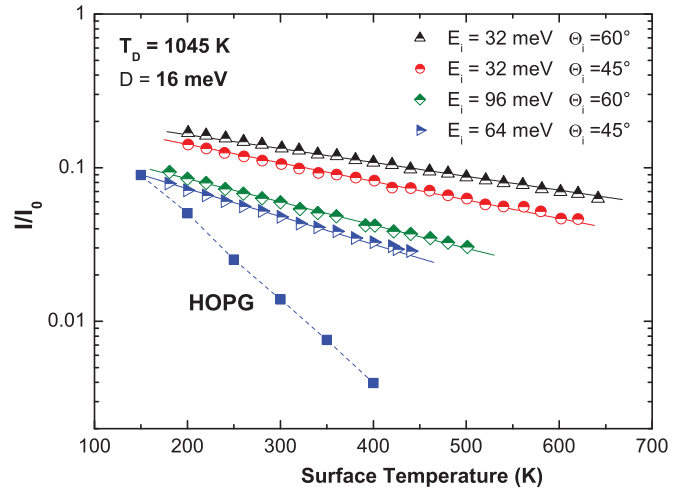


FIG. 3. (Color online) He specular intensity dependence for MLG/Ru(0001) as a function of surface temperature, for different incidence angles and energies. The incidence direction was along the $[11\bar{2}0]$ azimuth. Solid lines show the temperature dependence obtained using fits to Eqs. (1) and (2) and the best-fit D value quoted in the text. The corresponding Debye temperature is 1045 K. For comparison, the curve reported in Ref. 26 for HOPG at $E_i = 63 \text{ meV}$ and $\Theta_i = 45^\circ$ is also shown.

specular beam, $W(T)$ can be expressed as a function of the incident beam energy E_i and the angle of incidence θ_i :⁵

$$W(T) = \frac{12m(E_i \cos^2 \theta_i + D)T}{Mk_B \Theta_D^2}, \quad (2)$$

where M is the mass of a surface atom, m is the mass of the incoming particle, k_B is the Boltzmann constant, Θ_D is the surface Debye temperature, and D is the potential well depth. It should be kept in mind that, in some cases, there might be an uncertainty in obtaining the surface Debye temperature from He scattering, since the incoming He atom may interact simultaneously with several surface atoms (due to the long collision time) and then the effective mass M of the surface atom would have to be replaced by the mass of several atoms. In our case, the similar surface structure of supported graphene and graphite avoids this uncertainty.

The solid lines in Fig. 3 are the best fits to the data points using Eq. (2) and $M = 12$, corresponding to the mass of a single C atom. The best-fit parameters are $\Theta_D = 1045 \pm 25 \text{ K}$ and $D = 16 \pm 1 \text{ meV}$. The attractive potential depth is identical to the one obtained for a previous study on graphite.²⁶ Assuming that the effective mass is the same for graphite and graphene, the surface Debye temperature of HOPG is smaller than that of MLG/Ru(0001). The data in Fig. 3 also show that the MLG data follow the dependence on perpendicular momentum transfer predicted by Eq. (2).

These results represent experimental confirmation that the Debye temperature for supported graphene might be significantly higher than the value of 590 K reported for graphite.²⁶ The latter relates to the lattice vibrations along the c axis of graphite, i.e., the perpendicular motion of the outermost layer of graphite, and it is higher than the Debye temperature of most transition metal surfaces, possibly due to the specific phonon density of states of graphite.²⁶

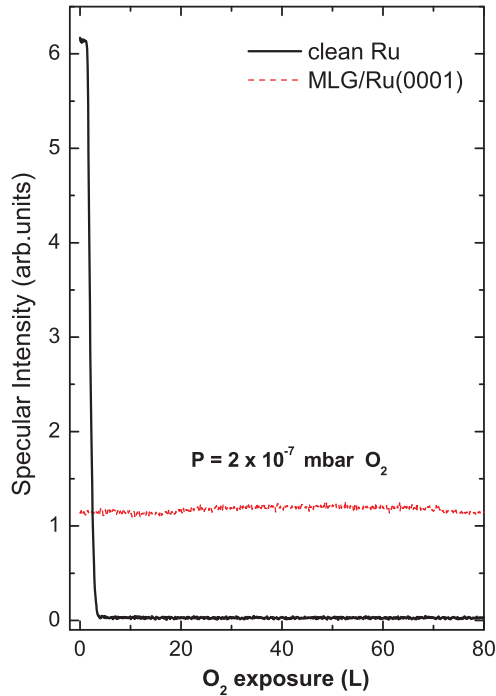


FIG. 4. (Color online) Behavior of the He specular intensity as a function of O_2 exposure for the clean Ru(0001) substrate (black solid curve) and for the MLG/Ru(0001) surface (red dashed curve). The sample temperature is 100 K.

The current results for MLG/Ru(0001) can be related to the strong bonding of graphene to Ru(0001),³³ which makes it

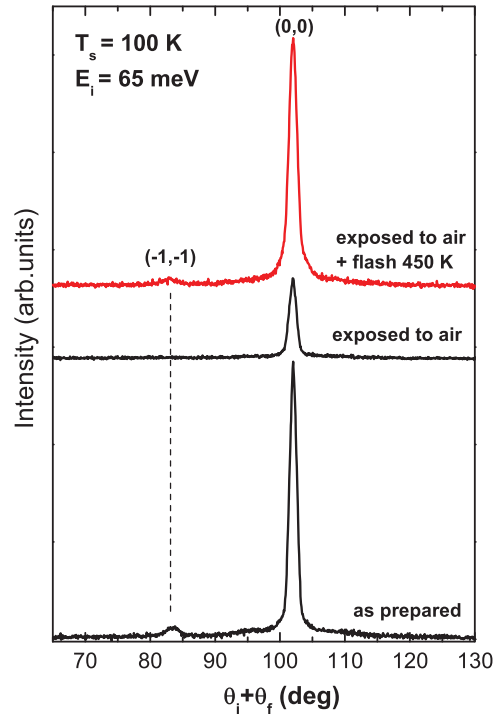


FIG. 5. (Color online) He diffraction in-plane spectra measured for an as-deposited MLG/Ru(0001) surface, successively exposed to air, and finally annealed to 450 K.

“harder” than graphite. These findings suggest that the number of low-frequency modes is smaller for graphene/Ru(0001) than for graphite.

On the other hand, it is surprising that the Debye temperature of 1287 K obtained for out-of-plane modes in isolated graphene by phonon Green’s function calculations³⁴ is close to the value derived from our data, 1045 K. We speculate that it might be due to the occurrence of a weak MLG-Ru bond in the higher regions of the ripples,³⁵ which are expected to have a predominant weight in the scattering of the impinging atomic beam. It should be noted that He-atom scattering experiments are not able to provide an estimation of the Debye temperature for planar modes [calculated to be 2000 K (Ref. 34)], as excitation of transverse modes is not possible within the scattering geometry used in the experiments. It is worth mentioning that the value reported in Ref. 34 is related to zero-point motion in free-standing graphene, while in the present measurements the motion corresponds to thermally activated vibrations.

In addition to the determination of the Debye temperature, the data in Fig. 3 allow us to identify the conditions needed to optimize the specular He reflectivity. From these data, we learn that by combining a large angle of incidence ($\Theta_i \sim 70^\circ$)

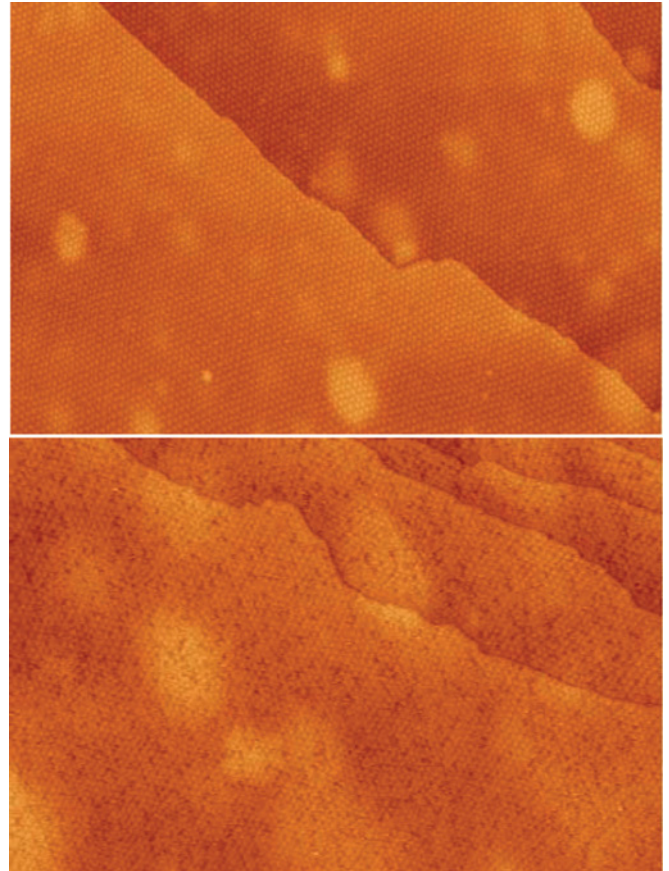


FIG. 6. (Color online) STM images ($3000 \times 2000 \text{ \AA}^2$) recorded with a bias voltage of -1 V and with a tunneling current of 0.1 nA for the as-deposited MLG on Ru(0001) before (top) and after air exposure without any thermal treatment (bottom). The ordered bright spots represent the moiré pattern due to the lattice mismatch between graphene and Ru(0001).

with an incidence energy close to $E_i \sim 10$ meV, while keeping the surface at 50 K, the specular reflectivity could be increased up to 30%. As a consequence, a SHeAM designed to use these surfaces as mirrors could achieve a signal-to-noise ratio two orders of magnitude larger than current prototypes, which would imply a significant improvement in the lateral resolution achievable.

A practical requirement, however, for using this surface as a focusing mirror in SHeAM is its long-term stability when exposed to contaminants. We have investigated this issue by measuring the surface reactivity in more detail. The results are shown in Fig. 4. Both the bare substrate (black curve) and the MLG/Ru(0001) surface (red curve) were exposed to O_2 with the sample kept at 100 K, while monitoring the specular peak intensity (I_{00}). On the clean surface, a saturated O/Ru(0001) layer was formed in a few seconds, upon exposure to just 4 L of O_2 . As a consequence, and in spite of its high reflectivity (ca. 35%), the clean Ru substrate could not be used as a mirror due to its high reactivity.

On the other hand, oxygen adsorption does not occur on MLG/Ru(0001), as indicated by the nearly constant behavior of I_{00} during O_2 exposure. These findings demonstrate that MLG/Ru(0001) is inert even at 100 K. Previously, the reactivity of MLG toward oxygen has been addressed by studies performed only at room temperature,^{36,37} at which the physisorption of molecules is usually quite reduced with respect to the case of 100 K. In addition, we have exposed the sample to air for a few minutes and transferred it back to the UHV chamber. The results, presented in Fig. 5, show that a significant He-beam reflectivity is still obtained from MLG, even without performing any cleaning procedure, which is a very surprising result. We have also observed that the reflectivity of the as-deposited sample is fully recovered

(within our experimental error of 5%) after flash annealing the sample to 450 K, as illustrated by the red curve in Fig. 5. STM experiments carried out on the air-exposed sample (without any thermal treatment) show that the MLG/Ru(0001) film remains almost unaffected by the interaction with air (Fig. 6). In particular, after reintroduction of the sample into the UHV system, the same (12×12) Moiré pattern^{16,17,19} as in the as-deposited MLG sample was observed.

IV. CONCLUSIONS

We have demonstrated that MLG/Ru(0001) is an excellent mirror for He atoms, with an absolute specular reflectivity of 20%. This surface is thermally stable up to 1150 K and its He reflectivity remains almost unchanged even after exposure to air. On the basis of such findings, a significant improvement in the lateral resolution achievable is expected for the prototypes of the SHeAM designed to use MLG surfaces as mirrors. The MLG/Ru(0001) surface works as a mirror not only for He but also for H_2 beams, for which an extremely high reflectivity of 11% has been obtained. The Debye temperature for MLG/Ru(0001) has been determined to be 1045 K, a value significantly higher than the one reported for graphite²⁶ (590 K), and very close to the value of 1287 K calculated for self-suspended graphene.³⁴

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